

**STRUCTURE AND METHOD FOR FORMING A DIELECTRIC
CHAMBER AND ELECTRONIC DEVICE INCLUDING THE
DIELECTRIC CHAMBER**

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ABSTRACT OF THE DISCLOSURE

A method (and structure) that selectively forms a dielectric chamber on an electronic device by forming a dummy structure over a semiconductor substrate, depositing a dielectric layer over the dummy structure, forming an opening through the dielectric layer to the dummy structure, and removing the dummy structure to form the dielectric chamber.